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**Yakov Sidorin
Christoph A. Waechter**
Editors

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Contents

ix *Conference Committee*

SESSION 1 TUNABLE WGS AND WG SENSORS

- 647502 **Characterization of quality-factor tunable integrated silicon microtoroidal resonators** [6475-01]
J. Yao, D. Leuenberger, M. C. Wu, Univ. of California, Berkeley (USA)
- 647503 **Micro-photonic cylindrical waveguide based protein biosensor** [6475-02]
S. K. Padigi, K. Aasante, R. K. K. Reddy, V. S. R. Kovvuri, A. LaRosa, S. Prasad, Portland State Univ. (USA)
- 647504 **Optical waveguide biosensor based on two-dimensional diffractive elements obtained by nano-imprint lithography** [6475-03]
S. Grego, RTI International (USA); Y. Cao, Univ. of North Carolina, Charlotte (USA);
C. A. Bower, B. R. Stoner, RTI International (USA); T. J. Suleski, Univ. of North Carolina, Charlotte (USA)
- 647505 **Demonstration of a liquid core optical ring resonator sensor coupled with an ARROW waveguide array** [6475-04]
I. M. White, H. Oveys, X. Fan, Univ. of Missouri, Columbia (USA); T. L. Smith, J. Zhang, 3M Co. (USA)

SESSION 2 GLASS WG OPTICS

- 647507 **Glass integrated optics: state of the art and position toward other technologies (Invited Paper)** [6475-06]
J.-E. Broquin, Institut de Microélectronique, Electromagnétisme et Photonique, INP Grenoble (France)

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The CID number appears on each page of the manuscript. The complete citation is used on the first page, and an abbreviated version on subsequent pages.

- 647508 **Chalcogenide waveguide for IR optical range** [6475-07]
M. L. Anne, V. Nazabal, V. Moizan, C. Boussard-Pledel, B. Bureau, J. L. Adam, Equipe Verres et Céramiques, CNRS, Univ. Rennes I (France); P. Nemec, M. Frumar, Univ. of Pardubice (Czech Republic); A. Moreac, Groupe Matière condensée et Matériaux, CNRS, Univ. Rennes I (France); H. Lhermite, IETR-Microelectronique, Univ. Rennes I (France); P. Camy, J. L. Doualan, CNRS-CEA-ENSICAEN, Univ. Caen (France); J. P. Guin, LARMAUER, CNRS, Univ. Rennes I (France); J. Le Person, F. Colas, C. Compere, M. Lehaitre, IFREMER (France); F. Henrio, D. Bosc, J. Charrier, École Nationale Supérieure des Sciences Appliquées et de Technologie (France); A.-M. Jurduc, B. Jacquier, LPCML, Univ. de Lyon I (France)
- 647509 **Channel waveguides fabrication in Er³⁺-doped tellurite glass by ion beam irradiation** [6475-08]
S. Berneschi, Istituto di Fisica Applicata Nello Carrara-CNR (Italy) and Univ. of Bologna (Italy); M. Brenchi, Istituto di Fisica Applicata Nello Carrara-CNR (Italy); G. Nunzi Conti, Enrico Fermi Ctr. for Study and Research (Italy) and Istituto di Fisica Applicata Nello Carrara-CNR (Italy); S. Pelli, G. C. Righini, Istituto di Fisica Applicata Nello Carrara-CNR (Italy); I. Bányász, A. Watterich, Research Institute for Solid State Physics and Optics (Hungary); N. Q. Khanh, M. Fried, Research Institute for Technical Physics and Materials Science (Hungary); F. Pásztí, Research Institute for Particle and Nuclear Physics (Hungary)
- 64750A **Three-dimensional integration of passive functions on glass by means of selectively buried waveguides and multiple ion-exchanges** [6475-09]
J. Grelin, D. Bucci, E. Ghibaudo, J.-E. Broquin, Institut de Microélectronique, Electromagnétisme et Photonique, INP Grenoble (France)

SESSION 3 SUBWAVELENGTH DIFFRACTIVE PHOTONICS

- 64750B **A reconfigurable self-collimation-based photonic crystal switch in silicon (Invited Paper)** [6475-10]
R. Martin, A. Sharkawy, C. Chen, B. Miao, E. J. Kelmelis, D. W. Prather, EM Photonics (USA)
- 64750C **Distributed subwavelength grating demultiplexer in SOI** [6475-11]
E. Bisailon, McGill Univ. (Canada); D. T. H. Tan, Univ. of British Columbia (Canada); M.-C. Nadeau, McGill Univ. (Canada); L. Chrostowski, Univ. of British Columbia (Canada); A. Kirk, McGill Univ. (Canada)
- 64750E **Narrowband Bragg reflectors in Ti:LiNbO₃ optical waveguides and implantation to optical modulators** [6475-13]
R. Kim, Advanced Micro Devices (USA); J. Zhang, 3M Corp. Research Materials Lab. (USA); O. Eknayan, H. F. Taylor, Texas A&M Univ. (USA); T. L. Smith, 3M Corp. Research Materials Lab. (USA)
- 64750F **The quarter-wave Bragg reflection waveguide: analytical solutions and properties** [6475-14]
B. R. West, McGill Univ. (Canada); A. Helmy, Univ. of Toronto (Canada)

SESSION 4 MODELING

- 64750G **Self-focusing in high-power optical fibers (Invited Paper)** [6475-15]
G. R. Hadley, A. V. Smith, Sandia National Labs. (USA)

- 64750H **Goal oriented adaptive finite element method for precise simulation of optical components** [6475-16]
L. Zschiedrich, S. Burger, J. Pomplun, F. Schmidt, Zuse Institute Berlin (Germany) and JCMwave GmbH (Germany)
- 64750I **Design issues with MMI-based photonics switches and routers** [6475-17]
L. W. Cahill, La Trobe Univ. (Australia)
- 64750J **Light extraction from OLEDs: the waveguide perspective** [6475-18]
N. Danz, D. Michaelis, C. Wächter, Fraunhofer-Institut für Angewandte Optik und Feinmechanik (Germany)
- 64750K **Theoretical analysis of active ring microresonator filter** [6475-19]
H. Chen, Yangtze Univ. (China) and College of Optical Sciences, Univ. of Arizona (USA)
- 64750L **Automatic design and optimisation of Si nanophotonics devices using finite element frequency domain solvers** [6475-20]
T. P. Felici, D. F. G. Gallagher, L. Bolla, Photon Design (United Kingdom)

SESSION 5 RECENT ADVANCES

- 64750M **Closed-loop design of a semiconductor laser (Invited Paper)** [6475-21]
J. V. Moloney, J. Hader, Nonlinear Control Strategies Inc. (USA), College of Optical Sciences, Univ. of Arizona (USA), and Univ. of Arizona (USA); L. Fan, M. Fallahi, College of Optical Sciences, Univ. of Arizona (USA); S. W. Koch, W. Stolz, Univ. of Marburg (Germany)
- 64750N **Integrated optoelectronics in an optical fiber (Invited Paper)** [6475-22]
J. V. Badding, Pennsylvania State Univ. (USA); P. J. Sazio, Univ. of Southampton (United Kingdom); V. Gopalan, Pennsylvania State Univ. (USA); A. Amezcua Correa, Univ. of Southampton (United Kingdom); T. J. Scheidemantel, Pennsylvania State Univ. (USA); C. E. Finlayson, Univ. of Southampton (United Kingdom); N. F. Baril, B. R. Jackson, D. Wong, Pennsylvania State Univ. (USA)
- 64750P **A new physical approach to understanding bend loss in optical fibers (Invited Paper)** [6475-24]
J. D. Love, C. Durniak, The Australian National Univ. (Australia)

SESSION 6 PLASMONICS

- 64750Q **Design of mid-infrared photodetectors enhanced by surface plasmons on grating structures** [6475-25]
Z. Yu, G. Veronis, M. L. Brongersma, S. Fan, Stanford Univ. (USA)
- 64750R **SPR waveguide sensor based on combined sensing of phase and amplitude changes** [6475-26]
R. Levy, S. Ruschin, Tel-Aviv Univ. (Israel)
- 64750S **Compact couplers between dielectric and plasmonic slot waveguides** [6475-27]
G. Veronis, S. Fan, Stanford Univ. (USA)

- 64750U **Long-range surface plasmon waveguides and devices in lithium niobate: preliminary results** [6475-29]
P. Berini, Univ. of Ottawa (Canada) and Spectalis Corp. (Canada); G. Mattiussi, N. Lahoud, R. Charbonneau, Spectalis Corp. (Canada)

SESSION 7 SUBWAVELENGTH AND MICROSTRUCTURES

- 64750V **Digital holographic microscopy for nanometric quality control of micro-optical components** [6475-31]
J. Kühn, F. Charrière, École Polytechnique Fédérale de Lausanne (Switzerland); T. Colomb, École Polytechnique Fédérale de Lausanne (Switzerland) and DP-CHUV (Switzerland); E. Cuhe, Y. Emery, Lyncée Tec SA (Switzerland); C. Depeursinge, École Polytechnique Fédérale de Lausanne (Switzerland)
- 64750X **Two-photon absorption for the realization of optical waveguides on printed circuit boards** [6475-34]
G. Langer, M. Riester, Austria Technologie & Systemtechnik (Austria)
- 64750Y **Micro ring cavity resonator incorporating total internal reflection mirrors** [6475-35]
D. G. Kim, W. K. Choi, Y. W. Choi, Chung-Ang Univ. (South Korea); J. C. Yi, Hong-Ik Univ. (South Korea); Y. Chung, Kwangwoon Univ. (South Korea); N. Dagli, Univ. of California, Santa Barbara (USA)

SESSION 8 PHC-BASED DEVICES

- 64750Z **Nanophotonic integrated lasers (Invited Paper)** [6475-36]
M. Kamp, H. Scherer, Univ. Würzburg (Germany); K. Janiak, H. Heidrich, Fraunhofer HHI (Germany); R. Brenot, G.-H. Duan, Alcatel Thales III-V Lab. (France); H. Benisty, Institut d'Optique-LCFO (France); A. Forchel, Univ. Würzburg (Germany)
- 647510 **Superprism phenomena in 2D low index contrast polymer photonic crystal** [6475-37]
L. Wang, Univ. of Texas at Austin (USA); W. Jiang, Omega Optics Inc. (USA); X. Chen, J. Chen, S. Zhang, R. Chen, Univ. of Texas at Austin (USA)
- 647511 **Silicon-based low-loss photonic crystal waveguides** [6475-38]
D. Pergande, Martin Luther Univ. Halle-Wittenberg (Germany) and Univ. of Paderborn (Germany); A. Milenin, Max-Planck-Institute of Microstructure Physics (Germany); T. Geppert, Max-Planck-Institute of Microstructure Physics (Germany) and Univ. Paderborn (Germany); A. von Rhein, Univ. of Paderborn (Germany); R. B. Wehrspohn, Martin-Luther-Univ. Halle-Wittenberg (Germany) and Univ. of Paderborn (Germany)
- 647512 **Photonic crystal slab reflectors for compact passive and active optical devices** [6475-39]
S. Boutami, B. Benbakir, J. Leclercq, X. Letartre, P. Regreny, M. Garrigues, P. Viktorovitch, LEOM-CNRS, École Centrale de Lyon (France); L. Legratiet, G. Beaudoin, I. Sagnes, LPN-CNRS (France)
- 647513 **Nanofluidic tuning of photonic crystal circuits** [6475-40]
D. Erickson, Cornell Univ. (USA); T. Rockwood, T. Emery, A. Scherer, D. Psaltis, California Institute of Technology (USA)

SESSION 9 NOVEL MATERIALS

- 647517 **Tailored nanoaggregates from functionalized organic molecules** [6475-44]
M. Schiek, Univ. of Oldenburg (Germany); J. Brewer, Univ. of Southern Denmark (Denmark);
F. Balzer, Univ. of Oldenburg (Germany); A. Lützen, Univ. of Bonn (Germany); K. Al-Shamery,
Univ. of Oldenburg (Germany); H.-G. Rubahn, Univ. of Southern Denmark (Denmark)
- 647518 **Microfabrication of integrated atomic vapor cells** [6475-45]
D. B. Conkey, R. L. Brenning, A. R. Hawkins, Brigham Young Univ. (USA); W. Yang, B. Wu,
H. Schmidt, Univ. of California, Santa Cruz (USA)

POSTER SESSION

- 647519 **Improvement of the signal-to-noise ratio in a glass-based guided-wave optical microphone** [6475-46]
H. Nikkuni, Y. Mogi, M. Hayashi, M. Ohkawa, S. Sekine, T. Sato, Niigata Univ. (Japan)
- 64751A **Silicon p-i-n optical waveguide modulators fabricated on the silicon and silicon-on-insulator substrates** [6475-47]
M.-T. Hsu, R. W. Chuang, J.-C. Liao, National Cheng Kung Univ. (Taiwan)
- 64751B **Broadband emission of GaAs/AlGaAs quantum-well superluminescent diode at 850 nm** [6475-48]
C. E. Dimas, C. T. Vishton, R. A. Merola, H. S. Djie, B. S. Ooi, Lehigh Univ. (USA)
- 64751C **Image quality improved 1X8 multimode interference coupler** [6475-49]
X. Wang, R. T. Chen, The Univ. of Texas at Austin (USA)

Author Index

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- 1 Tunable WGs and WG Sensors

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Radioélectricité de Grenoble (France)

- 2 Glass WG Optics

Christoph A. Waechter, Fraunhofer-Institut für Angewandte Optik und
Feinmechanik (Germany)

- 3 Subwavelength Diffractive Photonics
Christoph M. Greiner, LightSmyth Technologies, Inc. (USA)
- 4 Modeling
Christoph A. Waechter, Fraunhofer-Institut für Angewandte Optik und
Feinmechanik (Germany)
- 5 Recent Advances
Yakov Sidorin, Photineer Technology Group (USA)
- 6 Plasmonics
Gualtiero Nunzi Conti, Istituto di Fisica Applicata Nello Carrara (Italy) and
Centro Studi e Ricerche Enrico Fermi (Italy)
- 7 Subwavelength and Microstructures
Trevor M. Benson, The University of Nottingham (United Kingdom)
- 8 PhC-based Devices
Robert L. Nelson, Air Force Research Laboratory (USA)
- 9 Novel Materials
Christoph A. Waechter, Fraunhofer-Institut für Angewandte Optik und
Feinmechanik (Germany)